

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Kwang Su Choe, et al.

Examiner: Marianne Padgett

Serial No.: 10/674,647

Art Unit: 1762

Filed: September 30, 2003

Docket: YOR920030293US1 (16818)

For: THIN BURIED OXIDES BY LOW-DOSE
OXYGEN IMPLANTATION INTO MODIFIED
SILICON

Confirmation No: 4796

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

TERMINAL DISCLAIMER

Sir:

International Business Machines Corporation, having a principal place of business at New Orchard Road, Armonk, NY, and owner of the entire right, title and interest in the above identified application, as evidenced by an assignment executed by the inventors on September 30, 2003, and filed in the United States Patent and Trademark Office on May 4, 2004 at reel 014564, frame 0507 hereby disclaims the terminal portion of any patent granted on the above-identified application which would extend beyond the expiration date of commonly assigned U.S. Patent No. 6,800,518, issued October 5, 2004, and hereby agrees that any patent so granted on the above-identified application shall be enforceable only for and during such period that the legal title of the patent shall be the same as the legal title to said commonly assigned U.S. Patent No. 6,800,518, this agreement to run with any patent granted on the above-identified

application and to be binding upon the grantees, its successors or assigns.

Respectfully submitted,


Robert M. Trepp, Esq.

Dated: 10-15-2007

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